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APPLICATION FOR PATENT

[Reference number]

OHMI006K

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November 25, 1999

[Designation]

Commissioner, Patent Office

[Title of the invention]

SEMICONDUCTOR DEVICE

Kr-CONTAINING SILICON OXIDE FILM INTEGRATED THEREINTO,

AND MANUFACTURING METHOD OF THE SILICON OXIDE FILM

[Number of claims]

10

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[Attached documents]

[Document]

Specification 1

[Document]

Drawing

[Document]

Abstract